# Manufacturing High-Quality Crystalline CsPbBr<sub>3</sub> Perovskite Photoactive Films in Open-Air

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## Background

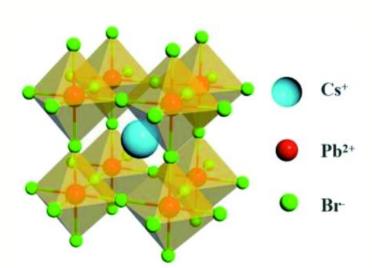


Fig.1: CsPbBr<sub>3</sub> crystal structure

- What is a perovskite? Compound with an ABX3 crystal structure (A=cation, B=Ge, Bi, Pb, Sn; X=halide). Emerging as a promising material for solar cells due to their high absorption, low cost, and scalability.
- Why CsPbBr<sub>3</sub>? This compound's inorganic nature creates a higher bandgap (~2.3 eV), making them ideal for tandem applications.
- **Problem Statement:** The crystal coverage and thickness must be optimized to prevent short circuits and maintain high efficiency.
- Approach: Starch can be added to slow down nucleation (number of crystals) in a cheap and non-toxic way. This will allow for crystal formation in the dendrite regime.
- **Dendrite Regime:** The dendrite regime is when rapid crystal formation leads to collisions between individual crystals. This phenomenon creates a continuous film.

### Goals

- Develop a continuous, light-absorbing crystal film perovskite films
- Aim for a perovskite thickness of ~500nm
- Utilize blade coating to enable scalable industrial production

# Dendrites solidify as

Fig.2: Crystal formation in the dendrite regime

### **Process**

- Cesium bromide, lead (II) bromide, solvent dimethyl sulfoxide(DMSO), and starch were combined and mixed in a glove box.
- Glass slides were coated using a blade coater set at a height of 1250µm, speed of 10mm/s, temperature of 40°C. The amount of ink on each film was an independent variable that ranged from 35-65µm based on the sample.
- After a sample was coated, it was transferred to a hot plate set at 250°C to anneal the perovskite crystals for 5 minutes.

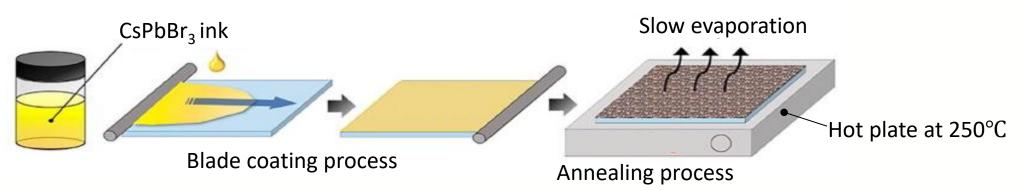
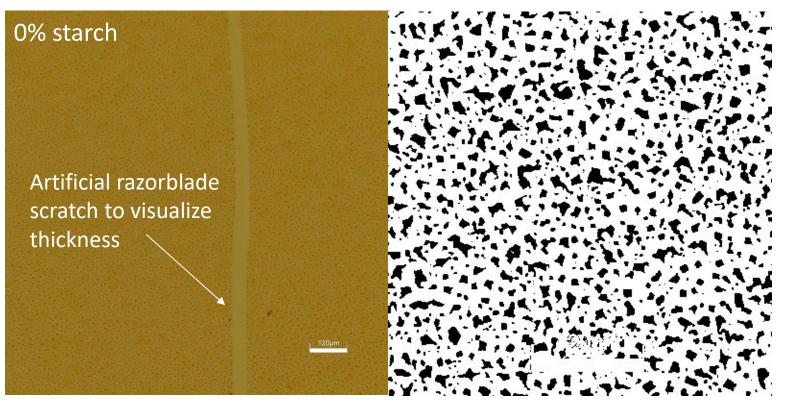
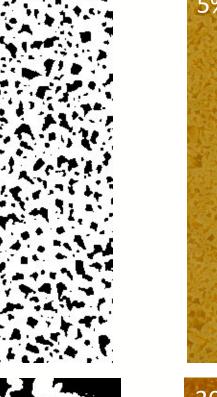


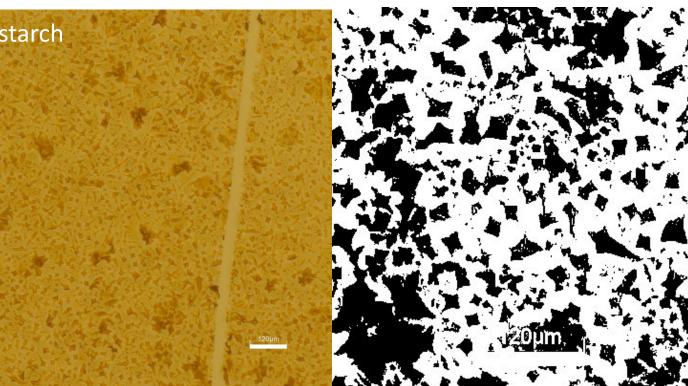
Fig.3: Blade Coating Procedure

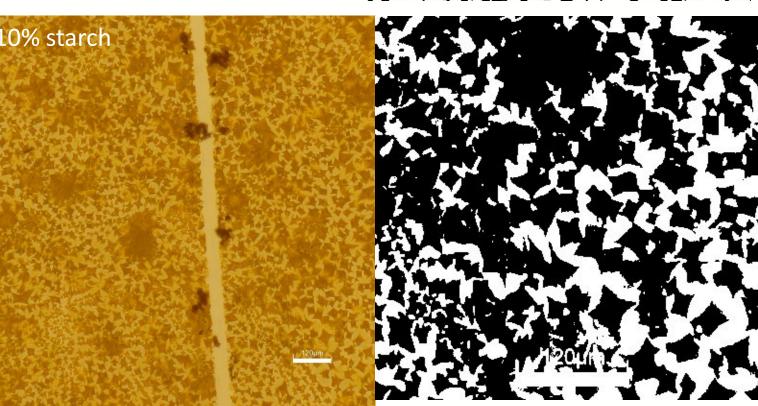
### **Findings**

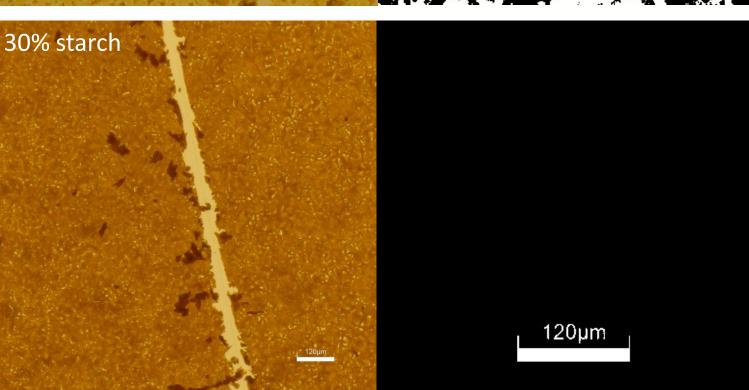
Four samples shown at 217x magnification with scratch and corresponding crystal coverage image (ImageJ software)











Amount of Starch	Crystal Coverage	Average Crystal Cluster Area	Average Thickness	Notes
0%	23.3%	40.7 μm <sup>2</sup>	305 nm	Poor crystal coverage
5%	37.6%	357 μm <sup>2</sup>	407 nm	Good thickness, poor coverage
10%	62.5%	3560 μm <sup>2</sup>	1,060 nm	Beginning of dendrite regime. Most promising sample set
30%	100%	N/A	5,790 nm	Dendrite regime achieved, too thick

### **Future Research**

- Fill in conducting gaps by blade coating a ~10 nm thick acrylic (polymethyl methacrylate or PMMA) layer on top of the 10% starch perovskites.
- Testing other conductive polymer materials and inorganic perovskite compounds such as CsPbl<sub>3</sub>



### **Acknowledgements**

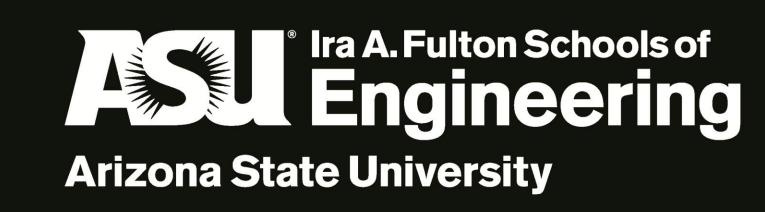


Figure 1: Gong M, Jiang D, Tao T, Chen F, Xu C, Zhi T, Liu W, Liu B, Zhang R, Zheng Y. 2021. Surface plasmon